

**SEVENTH SEMESTER B.TECH DEGREE EXAMINATION**

**13.701 NANOELECTRONICS (2013 SCHEME)**

**MODEL QUESTION PAPER**

Time: 3 Hours

Max. Marks: 100

**PART – A**

*Answer all questions. Each question carries 2 marks.*

1. Define any two characteristic lengths associated with nanoelectronic devices.
2. Quantum dots are considered as artificial atoms. Justify.
3. Draw the energy Vs wave vector diagram for a parabolic quantum well and list the features.
4. A dosage of  $10^{11}\text{cm}^{-2}$  is achieved while irradiating a sample of area  $100\text{cm}^2$  in an ion implantation equipment for a period of 60 seconds. Calculate the ion current.
5. Explain TEOS technique of  $\text{SiO}_2$  deposition.
6. List the merits of AFM over STM.
7. Explain the different types of multiple quantum well.
8. Suppose a metallic quantum dot, of shape similar to a flat circular disk of radius R parallel to an infinite metal plane, at a distance L from the plane. Show that in order to observe single electron effects at room temperature, the radius of the dot should be of the order of a few nanometers. Take as value of  $\epsilon_r$  the relative dielectric constant of silicon.
9. MODFETs are High Electron Mobility Transistors. Justify.
10. Explain the working of a RTD.

**PART – B**

*Answer any one full question from each module*

**MODULE -I**

11. (a) Derive the expression for density of states function of a 2D semiconductor nano structure.  
(b) What is the probability that a particle be found between 0.49 and 0.51 L in a 1D box of length L for  $n=1$ .
12. (a) Show that current in a quantum wire is proportional to group velocity and density of states.  
(b) Compare and contrast the features of square, triangular and parabolic quantum wells.

**MODULE -II**

13. (a) With simple schematic diagram, explain the principle of molecular beam epitaxy for fabricating nano layers.  
(b) DC sputtering cannot be used for the coating of non-conducting materials. Justify.
14. (a) Explain the different emission and interaction processes between electron beam and the sample.

(b) Illustrate the working principle of Atomic Force Microscope.

#### MODULE – III

15. (a) List and explain the major electron scattering mechanisms in parallel transport.  
(b) Explain Aharonov-Bohm effect.
16. (a) Explain Kronig-Penney model of a super lattice. What is meant by Zone folding?  
(b) Explain Integer Quantum Hall Effect.

#### MODULE - IV

17. Explain the concept of coulomb blockade. Derive the conditions to be fulfilled to observe single electron effect? Explain the principle of operation of a quantum dot based single electron transistor.
18. (a) Draw the schematic representation of the conduction band of a resonant tunnel diode for (i) no voltage applied (ii) increasing applied voltages. Explain its I-V characteristics.  
(b) Illustrate the working of a quantum well laser.